IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re Patent Application of P	Ally DKI	. 900-471 C# M#		
KOBAYASHI, S.	TC/A.U.	2825		^
Serial No. 10/632,850N0V 2 1 2005	Examiner:			
Filed: August 4, 2003	Date:	November 21, 2	2005	
Title: MASK PATTERN AND METHOD FOR MASK PATTERN THEREOF	FORMING RESIS	T PATTERN USIN	IG	
Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450				
Sir:			·-a	
This is a response/amendment/letter in the incorporated by reference and the signature signature thereon.	above-identified	ENDMENT/LETT application and i s the signature to	ncludes an attachment which is h	nereby of any other
☐ Correspondence Address Indi	ication Form	Attached.		
Fees are attached as calculated below: Total effective claims after amendment previously paid for 20 (at least 2)		ghest number \$50.00	\$0.00 (1202)/\$0.00 (2202)	\$
Independent claims after amendment previously paid for 3 (at least 3)		ghest number \$200.00	\$0.00 (1201)/\$0.00 (2201)	\$
If proper multiple dependent claims now ac	dded for first time	e, (ignore improp		•
Petition is hereby made to extend the curre paper and attachment(s)	One N Two Mo Three Mor	Month Extension nth Extensions \$ nth Extensions \$	\$360.00 (1051)/\$180.00 (2051) ing date of this \$120.00 (1251)/\$60.00 (2251) i450.00 (1252)/\$225.00 (2252) 1020.00 (1253/\$510.00 (2253) \$1590.00 (1254/\$795.00 (2254)	
Terminal disclaimer enclosed, add			\$130.00 (1814)/ \$65.00 (2814)	\$
☐ Applicant claims "small entity" status.	☐ Statement	filed herewith		
Rule 56 Information Disclosure Statement	Filing Fee		\$180.00 (1806)	\$
Assignment Recording Fee			\$40.00 (8021)	\$
Other:				\$
			TOTAL FEE ENCLOSED	
The Commissioner is hereby authorized to casserted to be filed, or which should have b firm) to our Account No. 14-1140. A <u>duplica</u>	een filed herewit	h (or with any pa	per hereafter filed in this applica	d, or tion by this
901 North Glebe Road, 11th Floor Arlington, Virginia 22203-1808 Telephone: (703) 816-4000 Facsimile: (703) 816-4100 JAR:caj			E P.C. Reg. No. 37,515	
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In re Patent Application of

KOBAYASHI, S.

Atty. Ref.: 900-471; Confirmation No.

Appl. No. 10/632,850

TC/A.U. 2825

Filed: August 4, 2003

Examiner: Dinh, P

For: MASK PATTERN AND METHOD FOR FORMING RESIST PATTERN USING MASK

PATTERN THEREOF

* * * * * * * * * *

November 21, 2005

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

AMENDMENT

Responsive to the Official Action dated August 30, 2005, please amend the above-identified application as follows: